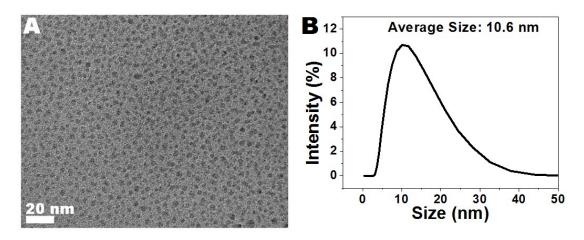
This PDF file includes: Figures S1 to S7.

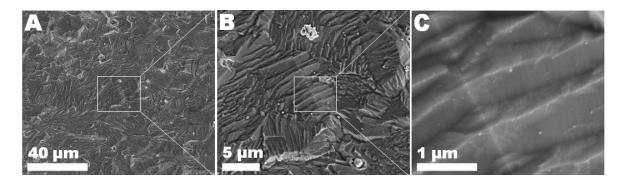
## **Electronic supplementary information**

## Low-current field-assisted assembly of copper nanoparticles for current collectors

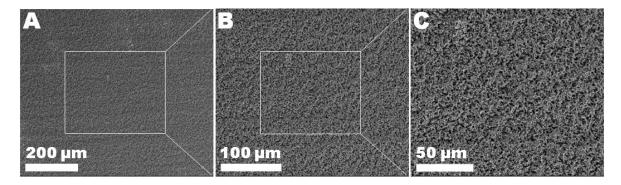
Lehao Liu, <sup>ab</sup> Bong Gill Choi, <sup>b</sup> Siu On Tung, <sup>c</sup> Tao Hu, <sup>b</sup> Yajie Liu, <sup>b</sup> Tiehu Li, <sup>a</sup> Tingkai Zhao <sup>a</sup> and Nicholas A. Kotov* <sup>bd</sup>
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<sup>c</sup> Macromolecular Science and Engineering, University of Michigan, Ann Arbor, Michigan 48109 USA
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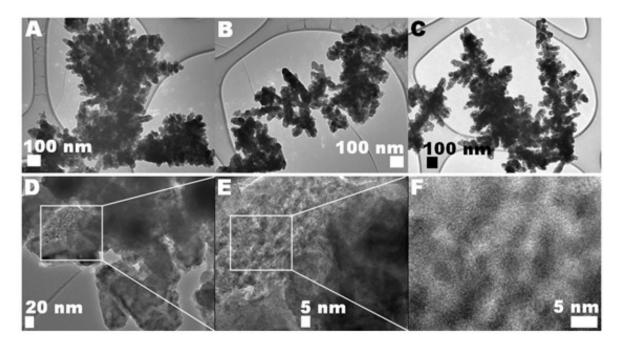
**Fig. S1**. **(A)** TEM image and **(B)** DLS size distribution of Cu NPs in dispersion. The larger size obtained in DLS data than in TEM images is attributed to the organic stabilizer shell and a relatively thick hydration layer.



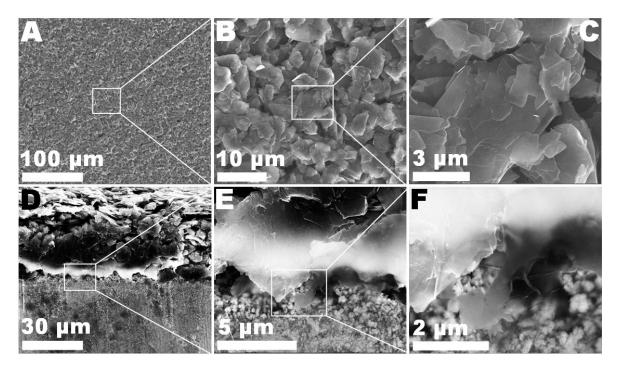
**Fig. S2**. (A-C) SEM images of Cu foil used for the preparation of NP-based film by field-stimulated assembly.



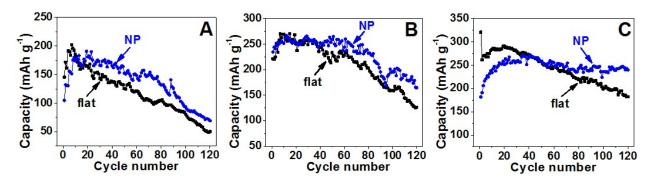
**Fig. S3**. (A-C) SEM images of 3D Cu film by field-stimulated assembly of Cu NPs at a potential of 2000 mV (current:  $\sim$ 75 mA) for 8 min.



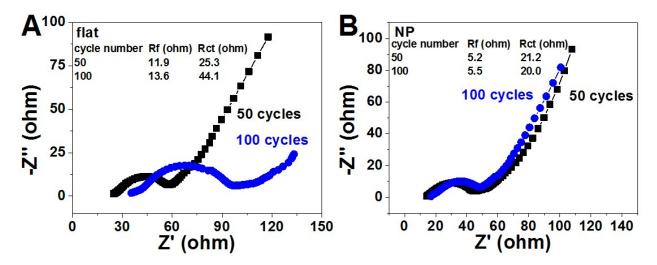
**Fig. S4**. (A-F) TEM images of the dendrites formed from Cu NPs during the field-stimulated assembly under a potential of 2000 mV (current:  $\sim$ 75 mA) for 8 min.



**Fig. S5**. (A-C) Top-view and (D-F) cross-sectional SEM images of dried graphite ( $\sim$ 3 mg) slurry coating on NP-based Cu current collector prepared under a potential of 2000 mV (current:  $\sim$ 75 mA) for 8 min.



**Fig. S6**. Cycle performance of **(A)** 11.5, **(B)** 7.0 and **(C)** 3.0 mg graphite on flat and NP-based Cu electrodes at 0.25 C rate, respectively.



**Fig. S7**. Impedance spectra of **(A)** flat and **(B)** NP-based Cu current collectors after 50 and 100 charge-discharge cycles at 0.25 C rate with 7.0 mg graphite loading.